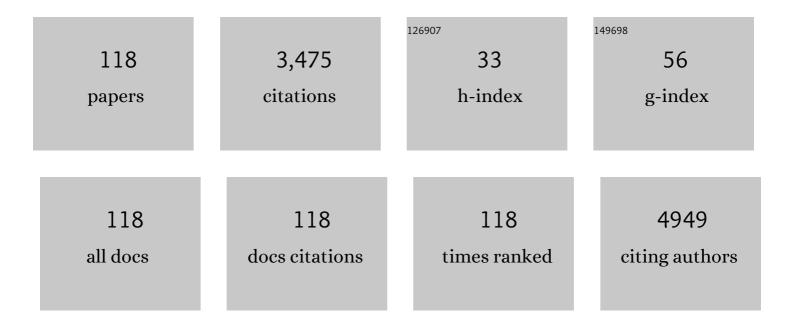
Dae-Geun Choi

List of Publications by Year in descending order

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#	Article	IF	CITATIONS
1	Enhancement of refractive index sensing for an infrared plasmonic metamaterial absorber with a nanogap. Optics Express, 2021, 29, 22796.	3.4	9
2	Fabrication of arrangement-controlled and vertically grown ZnO nanorods by metal nanotransfer printing. Journal of Industrial and Engineering Chemistry, 2020, 81, 385-392.	5.8	7
3	Dual nanotransfer printing for complementary plasmonic biosensors. Nanotechnology, 2019, 30, 385302.	2.6	4
4	Patterning of Functional Nanoparticles Using Solution-based Selective Surface Treatment Process. Journal of the Korean Society for Precision Engineering, 2019, 36, 1051-1057.	0.2	0
5	Oriented Grains with Preferred Lowâ€Angle Grain Boundaries in Halide Perovskite Films by Pressureâ€Induced Crystallization. Advanced Energy Materials, 2018, 8, 1702369.	19.5	74
6	Shapeâ€Controlled 3D Periodic Metal Nanostructures Fabricated via Nanowelding. Small, 2018, 14, 1703102.	10.0	20
7	Spontaneous Additive Nanopatterning from Solution Route Using Selective Wetting. ACS Applied Materials & Interfaces, 2018, 10, 26501-26509.	8.0	9
8	Plasmon-Enhanced Infrared Spectroscopy Based on Metamaterial Absorbers with Dielectric Nanopedestals. ACS Photonics, 2018, 5, 3492-3498.	6.6	43
9	Shape-controlled fabrication of nanopatterned samarium-doped cerium oxide thin films using ultraviolet nanoimprint lithography. Thin Solid Films, 2017, 636, 552-557.	1.8	2
10	Effects of polymer surface energy on morphology and properties of silver nanowire fabricated via nanoimprint and E-beam evaporation. Applied Surface Science, 2017, 420, 429-438.	6.1	13
11	Covalent bonding-assisted nanotransfer lithography for the fabrication of plasmonic nano-optical elements. Nanoscale, 2017, 9, 14335-14346.	5.6	28
12	Fabrication of high aspect ratio nanogrid transparent electrodes via capillary assembly of Ag nanoparticles. Nanoscale, 2016, 8, 11217-11223.	5.6	26
13	Highly efficient and stable cupronickel nanomesh electrode for flexible organic photovoltaic devices. Journal of Power Sources, 2016, 331, 22-25.	7.8	22
14	Facile Fabrication of Silicon Nanotube Arrays and Their Application in Lithiumâ€lon Batteries. Advanced Engineering Materials, 2016, 18, 1349-1353.	3.5	25
15	A cupronickel-based micromesh film for use as a high-performance and low-voltage transparent heater. Journal of Materials Chemistry A, 2015, 3, 16621-16626.	10.3	75
16	13.2% efficiency Si nanowire/PEDOT:PSS hybrid solar cell using a transfer-imprinted Au mesh electrode. Scientific Reports, 2015, 5, 12093.	3.3	84
17	Rapid Lowâ€Temperature 3D Integration of Silicon Nanowires on Flexible Substrates. Small, 2015, 11, 3995-4001.	10.0	2
18	A facile patterning of silver nanowires using a magnetic printing method. Nanotechnology, 2015, 26, 345301.	2.6	15

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19	Controlled Patterning of Vertical Silicon Structures Using Polymer Lithography and Wet Chemical Etching. Journal of Nanoscience and Nanotechnology, 2015, 15, 4522-4529.	0.9	3
20	ITO-free highly bendable and efficient organic solar cells with Ag nanomesh/ZnO hybrid electrodes. Journal of Materials Chemistry A, 2015, 3, 65-70.	10.3	55
21	Nanoimprinted ZnO and ZnO Quantum Dots Embedded SiO2 Layers for Inverted Bulk Heterojunction Solar Cells. Science of Advanced Materials, 2015, 7, 1253-1257.	0.7	1
22	Interior-architectured ZnO nanostructure for enhanced electrical conductivity via stepwise fabrication process. Nanoscale Research Letters, 2014, 9, 428.	5.7	8
23	Gold-coated silicon nanowire–graphene core–shell composite film as a polymer binder-free anode for rechargeable lithium-ion batteries. Physica E: Low-Dimensional Systems and Nanostructures, 2014, 61, 204-209.	2.7	16
24	Highâ€Durable AgNi Nanomesh Film for a Transparent Conducting Electrode. Small, 2014, 10, 3767-3774.	10.0	93
25	Enhanced Performance and Stability of Polymer BHJ Photovoltaic Devices from Dry Transfer of PEDOT:PSS. ChemSusChem, 2014, 7, 1957-1963.	6.8	23
26	Hysteresis and reversible red-shift in the reflectance spectra of single-layer porous silicon during exposure to various organic vapors. Journal of the Korean Physical Society, 2014, 64, 640-644.	0.7	2
27	Tailoring of the plasmonic and waveguide effect in bulk-heterojunction photovoltaic devices with ordered, nanopatterned structures. Organic Electronics, 2014, 15, 3120-3126.	2.6	3
28	Sub-100nm scale polymer transfer printing process for organic photovoltaic devices. Solar Energy Materials and Solar Cells, 2013, 109, 1-7.	6.2	7
29	Polymerâ€free Vertical Transfer of Silicon Nanowires and their Application to Energy Storage. ChemSusChem, 2013, 6, 2144-2148.	6.8	14
30	Layer-by-Layer All-Transfer-Based Organic Solar Cells. Langmuir, 2013, 29, 5377-5382.	3.5	22
31	Highly robust silicon nanowire/graphene core–shell electrodes without polymeric binders. Nanoscale, 2013, 5, 8986.	5.6	33
32	Superamphiphobic Surface by Nanotransfer Molding and Isotropic Etching. Langmuir, 2013, 29, 8070-8075.	3.5	87
33	Embossed superhydrophobic polymer surfaces with topological variances. Macromolecular Research, 2013, 21, 916-920.	2.4	8
34	Nanotransfer Molding of Free-Standing Nanowire and Porous Nanomembranes Suspended on Microtrenches. ACS Applied Materials & Interfaces, 2013, 5, 418-424.	8.0	3
35	Direct Nanoimprint of Metal Bilayer for Tunnable Metal Photonic Properties. Japanese Journal of Applied Physics, 2013, 52, 10MC09.	1.5	4
36	Effect of surface tension and coefficient of thermal expansion in 30 nm scale nanoimprinting with two flexible polymer molds. Nanotechnology, 2012, 23, 235303.	2.6	16

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37	Imprinted Pattern Profile-Dependent Optical Properties of Metal Nanostructures. Japanese Journal of Applied Physics, 2012, 51, 06FJ02.	1.5	0
38	Conformally direct imprinted inorganic surface corrugation for light extraction enhancement of light emitting diodes. Optics Express, 2012, 20, A713.	3.4	16
39	Surface plasmon-waveguide hybrid polymer light-emitting devices using hexagonal Ag dots. Optics Letters, 2012, 37, 761.	3.3	10
40	A Micro-System Based on Glass-Nanoporous Silicon for Optical Sensing of Organic Solvent Vapor. Journal of Nanoscience and Nanotechnology, 2012, 12, 4564-4569.	0.9	0
41	Polymer Solar Cells: Efficiency Increase in Flexible Bulk Heterojunction Solar Cells with a Nanoâ€Patterned Indium Zinc Oxide Anode (Adv. Energy Mater. 11/2012). Advanced Energy Materials, 2012, 2, 1282-1282.	19.5	1
42	Rapid nanopatterning of zirconium dioxide via nanoprinting and microwave-assisted annealing. RSC Advances, 2012, 2, 11035.	3.6	7
43	Fabrication of ZrO2 nanopatterns for biomimetic antireflection by thermal nanoimprint lithography. Microelectronic Engineering, 2012, 100, 12-15.	2.4	16
44	Graphoepitaxy of Blockâ€Copolymer Selfâ€Assembly Integrated with Single‣tep ZnO Nanoimprinting. Small, 2012, 8, 1563-1569.	10.0	36
45	Nanopatterning: Graphoepitaxy of Blockâ€Copolymer Selfâ€Assembly Integrated with Singleâ€Step ZnO Nanoimprinting (Small 10/2012). Small, 2012, 8, 1458-1458.	10.0	1
46	Efficiency Increase in Flexible Bulk Heterojunction Solar Cells with a Nanoâ€Patterned Indium Zinc Oxide Anode. Advanced Energy Materials, 2012, 2, 1319-1322.	19.5	40
47	Large-Area Nanotemplate Process and Its Application to Roll Imprint. Japanese Journal of Applied Physics, 2012, 51, 06FJ01.	1.5	2
48	Characterization of Adhesion Properties of a UV-Curable Nanoimprint Resin with Different Amounts of Release Agents. Journal of Adhesion, 2011, 87, 732-743.	3.0	0
49	Facile nanopatterning of zirconium dioxide films via direct ultraviolet-assisted nanoimprint lithography. Journal of Materials Chemistry, 2011, 21, 657-662.	6.7	35
50	Fabrication of nano-electrode arrays of free-standing carbon nanotubes on nano-patterned substrate by imprint method. Applied Surface Science, 2011, 257, 3063-3068.	6.1	9
51	Characterization of adhesion property between fused silica and thermoplastic polymer film in thermal nanoimprint lithography using a novel pull-off test. Microelectronic Engineering, 2011, 88, 855-860.	2.4	4
52	Optical characterization of anatase TiO2 films patterned by direct ultraviolet-assisted nanoimprint lithography. Microelectronic Engineering, 2011, 88, 923-928.	2.4	13
53	Optimized Film Processing of Nanosilver Colloids for Photoluminescence Enhancement. Journal of Nanoscience and Nanotechnology, 2011, 11, 422-426.	0.9	4
54	Fabrication and Photocatalytic Effects of Tungsten Trioxide Nano-Pattern Arrays. Materials Express, 2011, 1, 245-251.	0.5	5

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55	Pattern-Definable and Low Cost Fabrication of Nanopatterned Conducting Polymer Film on Flexible Substrates. Journal of Nanoscience and Nanotechnology, 2010, 10, 5680-5684.	0.9	0
56	Nanosilver Colloids-Filled Photonic Crystal Arrays for Photoluminescence Enhancement. Nanoscale Research Letters, 2010, 5, 1590-1595.	5.7	13
57	Effect of the ordered 2D-dot nano-patterned anode for polymer solar cells. Organic Electronics, 2010, 11, 285-290.	2.6	30
58	Corrugated organic light emitting diodes for enhanced light extraction. Organic Electronics, 2010, 11, 711-716.	2.6	76
59	Active layer transfer by stamping technique for polymer solar cells: Synergistic effect of TiOx interlayer. Organic Electronics, 2010, 11, 599-603.	2.6	22
60	Unexpected solid–solid intermixing in a bilayer of poly(3-hexylthiophene) and [6,6]-phenyl C61-butyric acidmethyl ester via stamping transfer. Organic Electronics, 2010, 11, 1376-1380.	2.6	37
61	Fabrication of free-standing carbon nanotube electrode arrays on a quartz wafer. Thin Solid Films, 2010, 518, 6624-6629.	1.8	5
62	A Simple Soft Lithographic Nanopatterning of Gold on Gallium Arsenide via Galvanic Displacement. Journal of Nanoscience and Nanotechnology, 2010, 10, 5020-5026.	0.9	6
63	Photovoltaic Devices with an Active Layer from a Stamping Transfer Technique: Single Layer Versus Double Layer. Langmuir, 2010, 26, 9584-9588.	3.5	38
64	Solution-processable polymer based photovoltaic devices with concentration graded bilayers made via composition control of a poly(3-hexylthiophene)/[6,6]-phenyl C61-butyric acidmethyl ester. Journal of Materials Chemistry, 2010, 20, 4910.	6.7	25
65	Fabrication of large area nanotemplate through nanosilver colloidal lithography. , 2010, , .		о
66	Photo-induced hybrid nanopatterning of titanium dioxide via direct imprint lithography. Journal of Materials Chemistry, 2010, 20, 1921.	6.7	40
67	Measurement of Surface Adhesion Force of Adhesion Promoter and Release Layer for UV-Nanoimprint Lithography. Journal of Nanoscience and Nanotechnology, 2009, 9, 769-773.	0.9	12
68	Mass fabrication of resistive random access crossbar arrays by step and flash imprint lithography. Nanotechnology, 2009, 20, 445305.	2.6	7
69	Direct Imprinted Conductive Patterns using Nanosilver Colloid-Applied UV Curable Resist. Japanese Journal of Applied Physics, 2009, 48, 06FH02.	1.5	7
70	Development of a very large-area ultraviolet imprint lithography process. Microelectronic Engineering, 2009, 86, 1983-1988.	2.4	14
71	Effect of surface treatments on interfacial adhesion energy between UV-curable resist and glass wafer. International Journal of Adhesion and Adhesives, 2009, 29, 662-669.	2.9	25
72	Direct imprint of conductive silver patterns using nanosilver particles and UV curable resin. Microelectronic Engineering, 2009, 86, 622-627.	2.4	12

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73	Nanosilver particles-based conductive patterns developed by direct soft imprint lithography. Current Applied Physics, 2009, 9, S138-S140.	2.4	5
74	Solution-processable polymer solar cells from a poly(3-hexylthiophene)/[6,6]-phenyl C61-butyric acidmethyl ester concentration graded bilayers. Applied Physics Letters, 2009, 95, 043505.	3.3	62
75	Fabrication of Plasma-induced Polymer Nanograss for a Synthetic Moth-eye Antireflection Nanostructure. Journal of the Korean Physical Society, 2009, 55, 566-571.	0.7	8
76	Nanoscopic Ordered Voids and Metal Caps by Controlled Trapping of Colloidal Particles at Polymeric Film Surfaces. Advanced Materials, 2008, 20, 4862-4867.	21.0	67
77	Patterned Colloidal Photonic Domes and Balls Derived from Viscous Photocurable Suspensions. Advanced Materials, 2008, 20, 3211-3217.	21.0	68
78	Direct soft UV-NIL with resist incorporating carbon nanotubes. Microelectronic Engineering, 2008, 85, 195-201.	2.4	11
79	A 4-inbased single-step UV-NIL tool using a low vacuum environment and additive air pressure. Microelectronic Engineering, 2008, 85, 2304-2308.	2.4	4
80	Selective removal of metallic SWNTs using microwave radiation. Current Applied Physics, 2008, 8, 725-728.	2.4	36
81	UV-curable nanoimprint resin with enhanced anti-sticking property. Applied Surface Science, 2008, 254, 4793-4796.	6.1	42
82	Measurement of Adhesion Force by a Symmetric AFM Probe for Nano-imprint Lithography Application. Journal of Adhesion Science and Technology, 2008, 22, 1379-1386.	2.6	7
83	Micropatterning of thin P3HT films via plasma enhanced polymer transfer printing. Journal of Materials Chemistry, 2008, 18, 3489.	6.7	48
84	Control of the Area Density of Vertically Grown ZnO Nanowires by Blending PS- <i>b</i> -P4VP and PS- <i>b</i> -PAA Copolymer Micelles. Chemistry of Materials, 2008, 20, 6041-6047.	6.7	22
85	Resist Flow Behavior in Ultraviolet Nanoimprint Lithography as a Function of Contact Angle with Stamp and Substrate. Japanese Journal of Applied Physics, 2008, 47, 8648-8651.	1.5	30
86	HYBRID NANOPATTERNING USING COLLOIDAL LITHOGRAPHY AND NANOIMPRINT FOR THE FABRICATION OF NANOTEMPLATE. International Journal of Nanoscience, 2008, 07, 73-79.	0.7	1
87	Direct UV-imprint lithography using conductive nanofiller-dispersed UV-curable resin. Journal of Vacuum Science & Technology B, 2008, 26, 1390.	1.3	4
88	Ultraviolet nanoimprinted polymer nanostructure for organic light emitting diode application. Applied Physics Letters, 2008, 92, 223307.	3.3	76
89	Effects of pattern size, dual side patterning, and imprint materials in the fabrication of antireflective structure using nanoimprint. , 2008, , .		0
90	Stamping-Based Planarization of Flexible Substrate for Low-Pressure UV Nanoimprint Lithography. Journal of Nanoscience and Nanotechnology, 2008, 8, 5673-5677.	0.9	0

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91	Etch-less UV-NIL process for patterning photonic crystal structure onto OLED substrate. Proceedings of SPIE, 2008, , .	0.8	0
92	Ultra-violet nanoimprint lithography applicable to thin-film transistor liquid-crystal display. , 2007, , .		2
93	Adaptive bonding technique for precise assembly of three-dimensional microstructures. Applied Physics Letters, 2007, 90, 233109.	3.3	8
94	Replication of an UV-NIL stamp using DLC coating. Microelectronic Engineering, 2007, 84, 899-903.	2.4	7
95	Controlled Fabrication of Hollow Metal Pillar Arrays Using Colloidal Masks. Chemistry of Materials, 2006, 18, 6103-6105.	6.7	31
96	Patterned Arrays of Au Rings for Localized Surface Plasmon Resonance. Langmuir, 2006, 22, 7109-7112.	3.5	122
97	Fabrication of fluorine-doped diamond-like carbon stamps for UV nanoimprint lithography. Nanotechnology, 2006, 17, 4659-4663.	2.6	13
98	Nanoscopic Pd Line Arrays Using Nanocontact Printed Dendrimers. Langmuir, 2006, 22, 3326-3331.	3.5	19
99	UV nanoimprint lithography using a diamond-like carbon stamp. , 2006, , .		5
100	Fabrication of Nano- and Micro-Scale UV Imprint Stamp Using Diamond-Like Carbon Coating Technology. Journal of Nanoscience and Nanotechnology, 2006, 6, 3619-3623.	0.9	5
101	Nanomachining by Colloidal Lithography. Small, 2006, 2, 458-475.	10.0	559
102	High-throughput step-and-repeat UV-nanoimprint lithography. Current Applied Physics, 2006, 6, e92-e98.	2.4	8
103	Multifaceted and Nanobored Particle Arrays Sculpted Using Colloidal Lithography. Advanced Functional Materials, 2006, 16, 33-40.	14.9	38
104	Ultraviolet-nanoimprint of 40 nm scale patterns using functionally modified fluorinated hybrid materials. Nanotechnology, 2006, 17, 3319-3324.	2.6	23
105	Fabrication of nano- and micro-scale UV imprint stamp using diamond-like carbon coating technology. Journal of Nanoscience and Nanotechnology, 2006, 6, 3619-23.	0.9	0
106	Controlled assembly of single SWNTs bundle using dielectrophoresis. Microelectronic Engineering, 2005, 81, 83-89.	2.4	94
107	Particle Arrays with Patterned Pores by Nanomachining with Colloidal Masks. Journal of the American Chemical Society, 2005, 127, 1636-1637.	13.7	50
108	Fluorinated Organicâ^'Inorganic Hybrid Mold as a New Stamp for Nanoimprint and Soft Lithography. Langmuir, 2005, 21, 9390-9392.	3.5	65

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109	Magnetic nanodot arrays patterned by selective ion etching using block copolymer templates. Nanotechnology, 2004, 15, 970-974.	2.6	22
110	UV nanoimprint lithography using a large area stamp in a low vacuum environment. , 2004, , .		0
111	2D nano/micro hybrid patterning using soft/block copolymer lithography. Materials Science and Engineering C, 2004, 24, 213-216.	7.3	35
112	Nanopatterned Magnetic Metal via Colloidal Lithography with Reactive Ion Etching. Chemistry of Materials, 2004, 16, 4208-4211.	6.7	54
113	Two-Dimensional Polymer Nanopattern by Using Particle-Assisted Soft Lithography. Chemistry of Materials, 2004, 16, 3410-3413.	6.7	48
114	Colloidal Lithographic Nanopatterning via Reactive Ion Etching. Journal of the American Chemical Society, 2004, 126, 7019-7025.	13.7	183
115	Effect of two-step sol–gel reaction on the mesoporous silica structure. Journal of Colloid and Interface Science, 2003, 261, 127-132.	9.4	49
116	Arrays of Binary and Ternary Particles and Their Replica Pores on Patterned Microchannels. Chemistry of Materials, 2003, 15, 4169-4171.	6.7	15
117	Incorporation of CdS Nanoparticles Inside Ordered Mesoporous Silica SBA-15 via Ion Exchange. Advanced Materials, 2002, 14, 1311-1314.	21.0	68
118	Rheological analysis of the gelation behavior of tetraethylorthosilane/ vinyltriethoxysilane hybrid solutions. Korean Journal of Chemical Engineering, 2002, 19, 190-196.	2.7	37